

OPY OF PAPERS
ORIGINALLY FILED

€ #-14/10/30/02 AD

Commissioner of Patents and Trademarks Washington, D.C. 20231

RECEIVED

George O. Saile, Reg. No. 19,572 20 McIntosh Drive Poughkeepsie, N.Y. 12603 OCT 25 2002 TECHNOLOGY CENTER 2800

Subject:

Serial No.: 09/325,951

Filed: 06/04/99

Inventor: Min-Hsiung Chiang

Title: Method For Forming High Purity Silicon Oxide Field

Oxide Isolation Region

Group Art Unit: 2812

Examiner: Pompey, R. E.

Attorney Docket: TSMC 98 - 262

RESPONSE TO PATENT OFFICE ACTION

Dear Sir:

In response to the Final office action dated 06/14/02 and as a Preliminary Amended to the Request for Continued Examination filed herewith, please consider the following remarks:

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to:. Commissioner of Patent and Trademarks, Washington, D.C. 20231, on October 15, 2002.

Signature/Date Stephen B. HCKerman, A

1

Docket: TSMC 98 - 262 S/N: 09/325,951

Charge to Deposit Account

The Commissioner is hereby authorized to charge payment of the fee of \$_____ associated with this communication, or credit any overpayment, to Deposit Account No. 19-0033. The Commissioner is also authorized to charge any

additional fee under 37 CFR §1.16 and 1.17 to this Deposit Account. A duplicate copy of

this sheet is enclosed. The Commissioner is hereby authorized to charge payment of any

additional fees involved with added Claims and the like to Deposit Account No.

19-0033.

Date

Respectively submitted,

George O. Saile; or

Stephen B. Ackerman